

L Number	Hits	Search Text	DB	Time stamp
1	10	(430/323).ccls. and nano	USPAT; US-PGPUB; IBM_TDB	2003/09/24 20:49
-	22	wiring adj substrate adj manufacturing adj method	USPAT; US-PGPUB; IBM_TDB	2003/09/19 13:23
-	1	(wiring adj substrate adj manufacturing adj method) and photomask	USPAT; US-PGPUB; IBM_TDB	2003/09/19 13:24
-	1	(wiring adj substrate adj manufacturing adj method) and photomask and nano	USPAT; US-PGPUB; IBM_TDB	2003/09/19 13:25
-	0	photomask and (nano adj particle)	USPAT; US-PGPUB; IBM_TDB	2003/09/19 13:25
-	11	photomask and (nano adj particle)	USPAT; US-PGPUB; IBM_TDB	2003/09/19 13:25
-	10	("3680028"   "4352835"   "4407695"   "4664748"   "4835392"   "5256587"   "5382315"   "5466627"   "5656349"   "5871870").PN.	USPAT	2003/09/22 16:42
-	1	photomask and (nano adj particle) and (black near (pigment or dye))	USPAT; US-PGPUB; IBM_TDB	2003/09/22 18:19
-	1214	29/832.cccls.	USPAT; US-PGPUB; IBM_TDB	2003/09/22 17:05
-	3	29/832.cccls. and nano	USPAT; US-PGPUB; IBM_TDB	2003/09/22 19:37
-	99	(toshihiko near tanaka).in.	USPAT; US-PGPUB; IBM_TDB	2003/09/22 17:48
-	1	(toshihiko near tanaka).in. and nano	USPAT; US-PGPUB; IBM_TDB	2003/09/22 17:49
-	0	(toshihiko adj tanaka).in.	USPAT; US-PGPUB; IBM_TDB	2003/09/22 17:50
-	99	(tanaka adj toshihiko).in.	USPAT; US-PGPUB; IBM_TDB	2003/09/22 17:50
-	1	(tanaka adj toshihiko).in. and nano	USPAT; US-PGPUB; IBM_TDB	2003/09/22 17:50
-	2	(kubo near masaharu).in. and nano	USPAT; US-PGPUB; IBM_TDB	2003/09/22 17:52
-	1	(hattori near takashi).in. and nano	USPAT; US-PGPUB; IBM_TDB	2003/09/22 17:52
-	10	("3680028"   "4352835"   "4407695"   "4664748"   "4835392"   "5256587"   "5382315"   "5466627"   "5656349"   "5871870").PN.	USPAT	2003/09/22 17:56
-	2	6007969.URPN.	USPAT	2003/09/22 18:13
-	17	(wiring adj substrate) and (nano)	USPAT; US-PGPUB; IBM_TDB	2003/09/22 18:23
-	769	(wiring) and (nano)	USPAT; US-PGPUB; IBM_TDB	2003/09/22 18:58
-	15	(wiring) and (nano) and photomask	USPAT; US-PGPUB; IBM_TDB	2003/09/22 18:23

-	264	(wiring) and (nano) and mask	USPAT; US_PGPUB; IBM_TDB	2003/09/22 18:58
-	222	(wiring) and (nano) and mask and substrate	USPAT; US_PGPUB; IBM_TDB	2003/09/22 18:59
-	222	(method or process or step) and (wiring) and (nano) and mask and substrate	USPAT; US_PGPUB; IBM_TDB	2003/09/22 18:59
-	14	(method or process or step) and (wiring near substrate) and (nano) and mask and substrate	USPAT; US_PGPUB; IBM_TDB	2003/09/22 18:59
-	10	("3680028"   "4352835"   "4407695"   "4664748"   "4835392"   "5256587"   "5382315"   "5466627"   "5656349"   "5871870").PN.	USPAT	2003/09/22 19:08
-	2	29/846.cccls. and nano	USPAT; US_PGPUB; IBM_TDB	2003/09/22 19:37
-	2	29/847.cccls. and nano	USPAT; US_PGPUB; IBM_TDB	2003/09/22 19:39
-	4	430/319.cccls. and nano	USPAT; US_PGPUB; IBM_TDB	2003/09/24 11:53
-	23	(430/321,5).cccls. and nano	USPAT; US_PGPUB; IBM_TDB	2003/09/24 12:42
-	5	("5178978"   "5371817"   "5471552"   "5550088"   "5915051").PN.	USPAT	2003/09/24 11:57
-	1924	mask and nano	USPAT; US_PGPUB; IBM_TDB	2003/09/24 12:43
-	1786	mask and nano and (conductive or conductor or wire or wiring or trace or track or line)	USPAT; US_PGPUB; IBM_TDB	2003/09/24 12:44
-	198	(photomask or (photo adj mask)) and nano and (conductive or conductor or wire or wiring or trace or track or line)	USPAT; US_PGPUB; IBM_TDB	2003/09/24 13:05
-	198	(method or process or step) and (photomask or (photo adj mask)) and nano and (conductive or conductor or wire or wiring or trace or track or line)	USPAT; US_PGPUB; IBM_TDB	2003/09/24 14:03
-	97	(method or process or step) with (photomask or (photo adj mask)) and nano and (conductive or conductor or wire or wiring or trace or track or line)	USPAT; US_PGPUB; IBM_TDB	2003/09/24 13:06
-	2	(method or process or step) with (photomask or (photo adj mask)) with nano and (conductive or conductor or wire or wiring or trace or track or line)	USPAT; US_PGPUB; IBM_TDB	2003/09/24 13:05
-	93	(method or process or step) with (photomask or (photo adj mask)) and nano and (conductive or conductor or wire or wiring or trace or track or line) and substrate	USPAT; US_PGPUB; IBM_TDB	2003/09/24 13:14
-	10	(method or process or step) with (photomask or (photo adj mask)) and nano with (conductive or conductor or wire or wiring or trace or track or line) and substrate	USPAT; US_PGPUB; IBM_TDB	2003/09/24 13:14
-	23	(method or process or step) and (photomask or (photo adj mask)) and nano and binder	USPAT; US_PGPUB; IBM_TDB	2003/09/24 13:18
-	1326	(method or process or step) near (photomask or (photo adj mask))	USPAT; US_PGPUB; IBM_TDB	2003/09/24 13:19
-	1062	(method or process or step) near (photomask)	USPAT; US_PGPUB; IBM_TDB	2003/09/24 13:19

-	10	(method or process or step) near (photomask) and nano	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 13:20
-	130	(method or process or step) near (mask) and nano	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 13:21
-	4	(method or process or step) near (mask) with nano	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 13:26
-	38	(method or process or step) with (mask) with nano	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 13:26
-	1	(method or process or step) with (mask) with nano with glass	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 13:26
-	10	("3680028"   "4352835"   "4407695"   "4664748"   "4835392"   "5256587"   "5382315"   "5466627"   "5656349"   "5871870").PN.	USPAT	2003/09/24 13:29
-	3	("4407695"   "5510156"   "5695658").PN.	USPAT	2003/09/24 13:56
-	12	5871870.URPN.	USPAT	2003/09/24 14:00
-	86044	(method or process or step) with (mask or photomask or (photo adj mask))	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 14:04
-	38	(method or process or step) with (mask or photomask or (photo adj mask)) with nano	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 14:11
-	3793	(method or process or step) with (mask or photomask or (photo adj mask)) and pigment	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 14:12
-	596	(method or process or step) with (mask or photomask or (photo adj mask)) and (black adj pigment)	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 14:12
-	22	(method or process or step) with (mask or photomask or (photo adj mask)) with (black adj pigment)	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 14:18
-	76	(mask or photomask or (photo adj mask)) with (black adj pigment)	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 14:19
-	65	(mask or photomask or (photo adj mask)) with (black adj pigment) and glass	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 14:19
-	25	(mask or photomask or (photo adj mask)) with (black adj pigment) with glass	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 14:19
-	1	("6412305").PN.	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 15:27
-	1	("5746677").PN.	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 15:28
-	136	mask and pigment and glass and nano	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 15:31
-	117	mask and pigment and glass and nano and (wire or wiring or track or lead or conductor or trace)	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 15:31
-	117	(method or process or step) and mask and pigment and glass and nano and (wire or wiring or track or lead or conductor or trace)	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 15:32
-	4	(method or process or step) and mask and (black adj pigment) and glass and nano and (wire or wiring or track or lead or conductor or trace or line or conductive) and layer	USPAT; US-PPGPUB; IBM_TDB	2003/09/24 15:48
-	3	4465749.URPN.	USPAT	2003/09/24 15:39

-	1	mask with (black adj pigment) and glass and nano and (wire or wiring or track or lead or conductor or trace or line or conductive) and layer	USPAT; US-PGPUB; IBM_TDB	2003/09/24 15:48
-	43	mask with (black adj pigment) and glass and (wire or wiring or track or lead or conductor or trace or line or conductive) and layer	USPAT; US-PGPUB; IBM_TDB	2003/09/24 16:01
-	1	mask with (black adj pigment) and glass and (wire or wiring or track or lead or conductor or trace or line or conductive) and layer and nano	USPAT; US-PGPUB; IBM_TDB	2003/09/24 16:01
-	4	mask with (black adj pigment) and glass and (wire or wiring or track or lead or conductor or trace or line or conductive) and layer and micro	USPAT; US-PGPUB; IBM_TDB	2003/09/24 16:01
-	3660	photo adj etching	USPAT; US-PGPUB; IBM_TDB	2003/09/24 17:18
-	24	(photo adj etching) with positive	USPAT; US-PGPUB; IBM_TDB	2003/09/24 17:19
-	19	(photo adj etching) with positive and negative	USPAT; US-PGPUB; IBM_TDB	2003/09/24 18:32
-	12	(mask or photomask or (photo adj mask)) with (black adj pigment) with glass and carbon	USPAT; US-PGPUB; IBM_TDB	2003/09/24 17:54
-	1	carbon with (black adj pigment) with nano	USPAT; US-PGPUB; IBM_TDB	2003/09/24 17:55
-	7	carbon with (black adj pigment) with meter	USPAT; US-PGPUB; IBM_TDB	2003/09/24 17:56
-	1	carbon with (black adj pigment) with micro	USPAT; US-PGPUB; IBM_TDB	2003/09/24 17:56
-	12	carbon with (black adj pigment) with micrometer	USPAT; US-PGPUB; IBM_TDB	2003/09/24 17:57
-	12	(photo adj etching) with positive and negative and mask	USPAT; US-PGPUB; IBM_TDB	2003/09/24 18:32